

# Novel Concepts of a High-Brightness RF Gun

*S.V. Kuzikov<sup>2,3</sup>, S. Antipov<sup>2</sup>, O.A. Ivanov, A.A. Vikharev, A.L. Vikharev*

Institute of Applied Physics, Russian Academy of Sciences, Nizhny Novgorod, Russia

<sup>2</sup>Euclid Techlabs LLC, Bolingbrook, IL, USA

<sup>3</sup>Lobachevsky University of Nizhny Novgorod, Nizhny Novgorod, Russia

## Outline

1. High cathode fields produced by short high-power RF pulses
2. Low-temperature diamond cathode
3. Pre-acceleration by a single-cycle THz pulse and ultrafast field emission gating
4. Conclusion

# Brightness and emittances

$$B = \frac{2I}{\mathcal{E}_{\perp}^2}, \quad \mathcal{E}_{\perp}^2 = \mathcal{E}_{th}^2 + \mathcal{E}_{sc}^2 + \mathcal{E}_{RF}^2$$

• High emission current and low space charge emittance become possible in case of high RF cathode field\*:

$$\mathcal{E}_{sc} = \frac{I}{\gamma' \cdot I_A \cdot (3\sigma_r / \sigma_z + 5)}, \quad \gamma' = \frac{eE_{cathode}}{m_e c^2}$$

High fields  $\geq 200$  MV/m are obtainable with short pulses only according to scaling laws for breakdown and pulse heating:

$$E_s^p \tau = const, p = 5 - 6. \quad H_s^2 \sqrt{\tau} = const.$$

• Short bunch length  $\sigma_z$  and low temperature semiconductor are also desirable:

$$\mathcal{E}_{RF} = \gamma' \cdot k_{RF}^2 \cdot \sigma_r^2 \cdot \sigma_z^2 \quad \text{-RF induced emittance for a bunch injected in the correct phase}$$

$$\mathcal{E}_{th} = \frac{R_c}{2} \sqrt{\frac{k_B T_c}{m_e c^2}} \quad \text{-thermal emittance}$$

where  $R_c$  is cathode radius,  $\sigma_r$ ,  $\sigma_z$  are transverse and longitudinal bunch sizes respectively,  $T_c$  – temperature of the cathode.

\*J.B. Rosenzweig et. al. “Next Generation High Brightness Electron Beams From Ultra-High Field Cryogenic Radiofrequency Photocathode Sources”, arXiv:1603.01657 (2016).

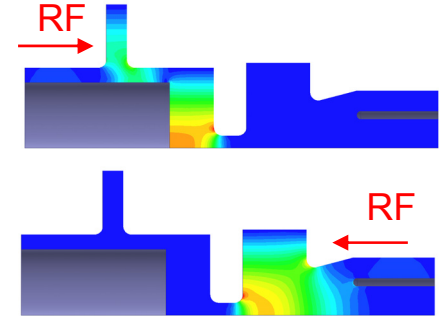
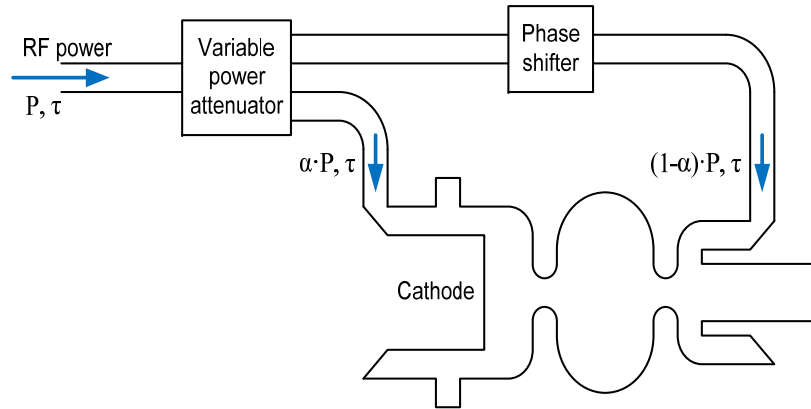
# RF system of high cathode field photoinjector

High fields are necessary in the first short cell only.

## 1) Standing wave structure

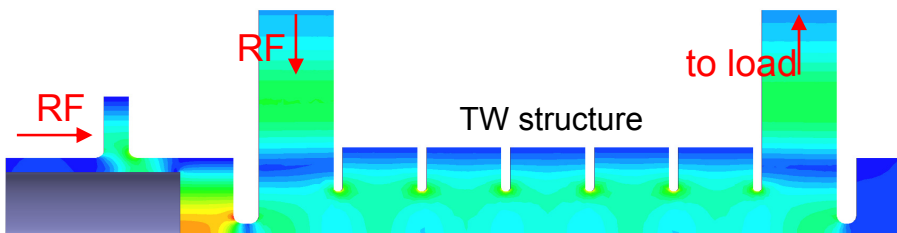
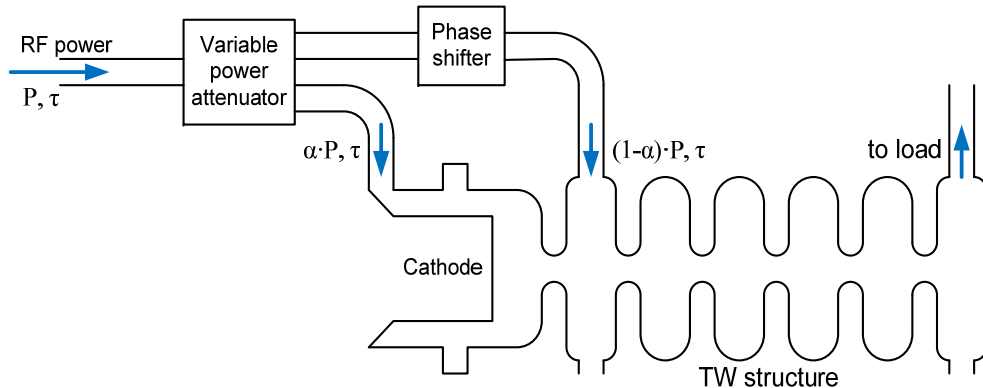
$$E_{cathode}^{max} \approx 500 MV / m \text{ in the first cell at } 11.7 \text{ GHz}$$

Up to **300 MW**,  
**10 ns** at **11.7 GHz**  
(experiment in ANL with the structure excited by bunch train)

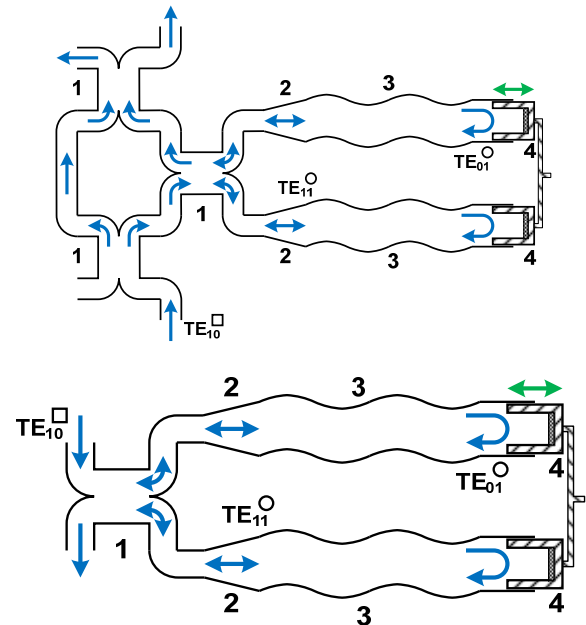


$$Q \approx \pi \cdot f \cdot \tau = 370 \text{ at } 11.7 \text{ GHz for } 10 \text{ ns}$$

## 2) Travelling wave structure

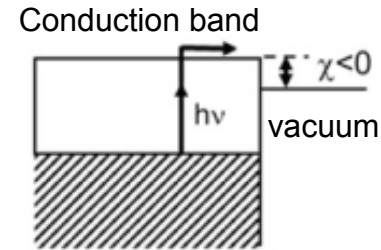
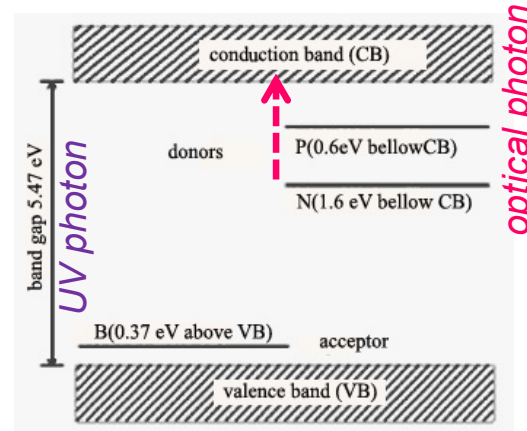
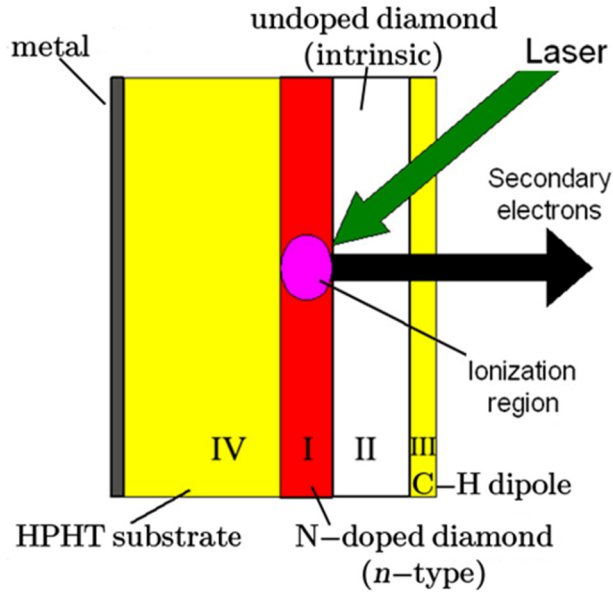


Power attenuator and phase shifter:

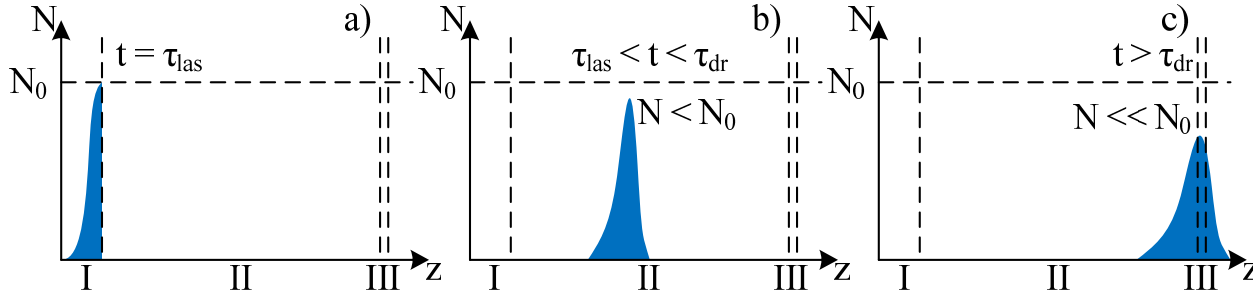


# High-brightness RF gun based on cold diamond photocathode with NEA

1. True negative electron affinity is obtainable at H-terminated surface.
2. Doped diamond cathode can be driven by optical laser.
3. Diamond does not require high vacuum.
4. Multi-layered CVD mono-crystal diamond is available.



Energy diagram and doping impurity levels in the band gap of diamond

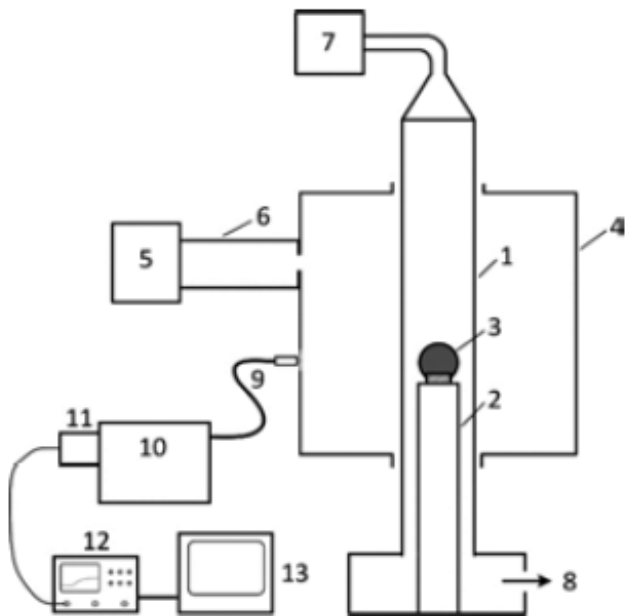


**Layer I** is a heavily *n*-doped diamond (source of free carriers).

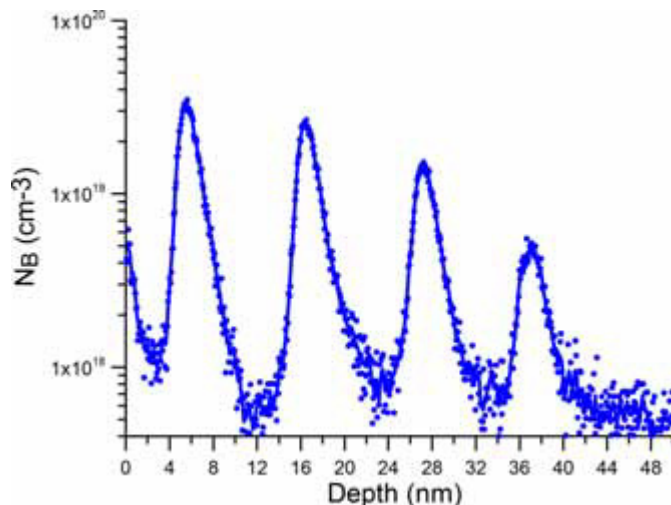
**Layer II** is nearly impurity-free intrinsic diamond (thermalizing layer).

**Layer III** is the H-terminated surface possessing the NEA property (emission layer). This layer should be Boron doped, in order to remove trapped electrons between pulses.

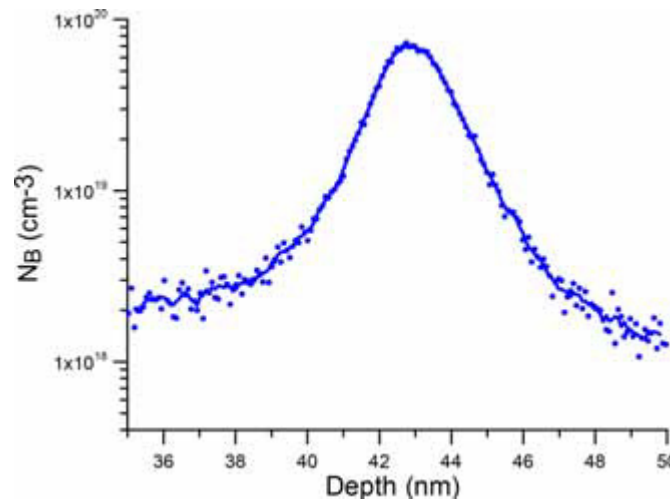
## 2.45 GHz MPACVD reactor for diamond delta-doping\*:



1 - quartz tube, 2 - substrate holder, 3 - plasma, 4 - cavity, 5 - 2.45 GHz magnetron, 6 - rectangular waveguide, 7 - gas feeding system, 8 - gas pumping system, 9 - optical fiber, 10 - SOLAR TII monochromator, 11 - PMT, 12 - oscilloscope, 13 - PC.



SIMS characterization of four boron delta-doped layers. Total thickness of CVD diamond is about 50 nm, the measurement started on the growth surface (depth = 0).



SIMS characterization of nanometric boron delta-doped layer. FWHM of the boron peak concentration is about 2 nm; the SIMS analysis starts from growth surface (depth = 0).

\*A.L. Vikharev *et al.* "Nanometric diamond delta doping with boron", *Physica status solidi (RRL)* - Rapid Research Letters 10, 324 (2016).

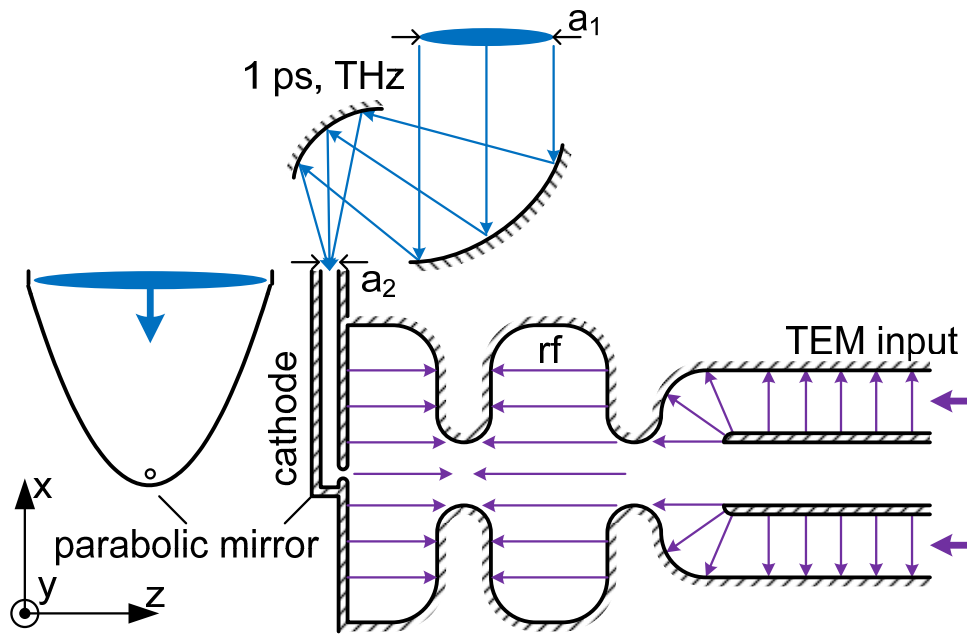


# Diamond photocathode performance, and anticipated parameters of the 11.7 GHz gun based on this photocathode:

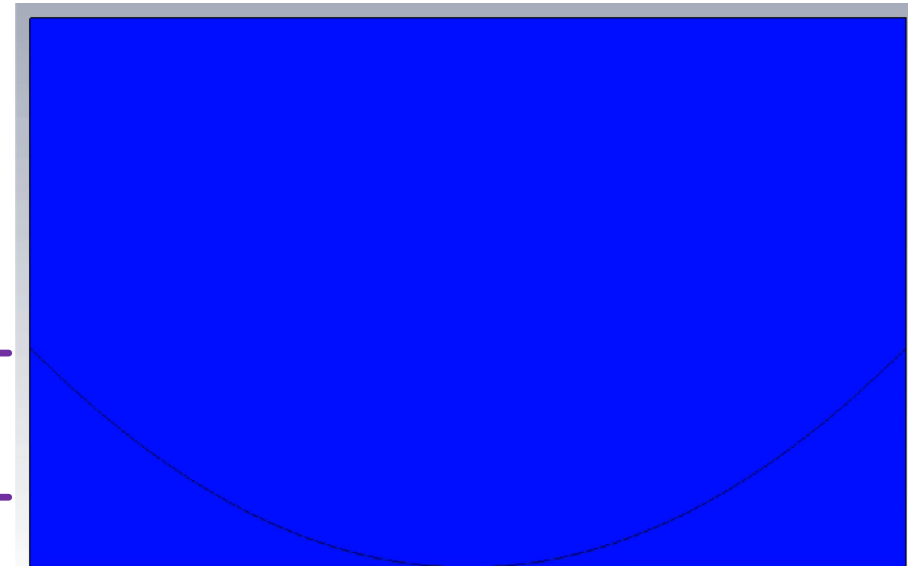
Laser pulse duration (ps)	0.1	0.3	0.5
Cathode radius (mm)	3	3	3
Wavelength (nm)	250-532	250-532	250-532
QE	$10^{-3}$ - $10^{-2}$	$10^{-3}$ - $10^{-2}$	$10^{-3}$ - $10^{-2}$
Bunch charge (pC)	100	100	100
Maximum electric field on cathode (MV/m)	500	500	500
Parameter $\alpha = \frac{e \cdot E_{RF} \cdot \lambda_{RF}}{4\pi \cdot m_e \cdot c^2}$	1.99	1.99	1.99
Launch phase (deg.)	75	75	75
$\epsilon_{th}$ at 80 K (mm×mrad)	0.17	0.17	0.17
$\epsilon_{sc}$ (mm×mrad)	0.2	0.2	0.2
$\epsilon_{RF}$ (mm×mrad)	$1.4 \times 10^{-2}$	0.13	0.35
Brightness (A/m <sup>2</sup> ×rad <sup>2</sup> )	$2.9 \times 10^{16}$	$7.8 \times 10^{15}$	$2.1 \times 10^{15}$

# RF gun with fast preliminary acceleration by short high-power THz pulses

- High-power, single cycle THz pulses ( $E$  up to 10 GV/m) can be produced by means of a rectification of laser pulses in nonlinear media.
- These pulses are able to inject high charge (up to 1 nC) and to accelerate electrons at high gradient.



Scheme of conventional RF gun supplemented by THz accelerating section

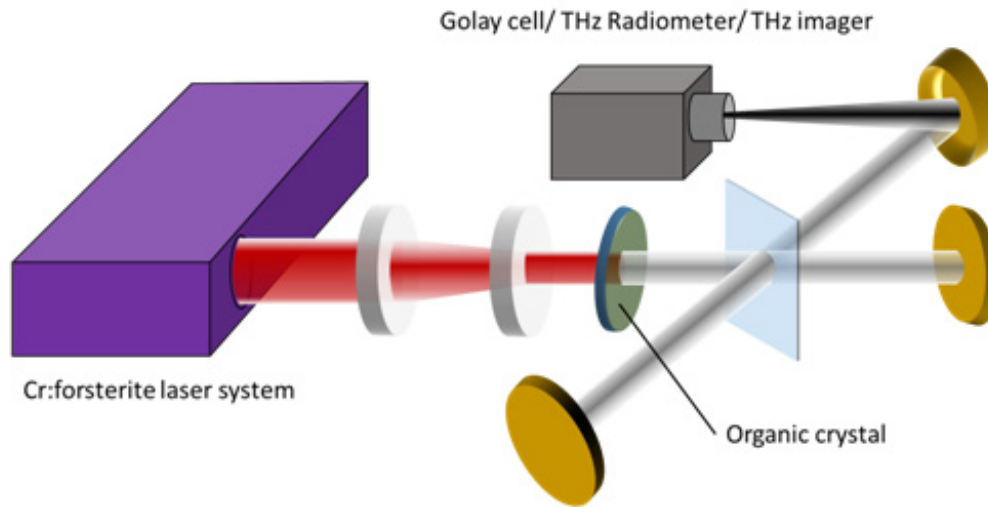


Focusing of 1 ps THz pulse by parabolic mirror



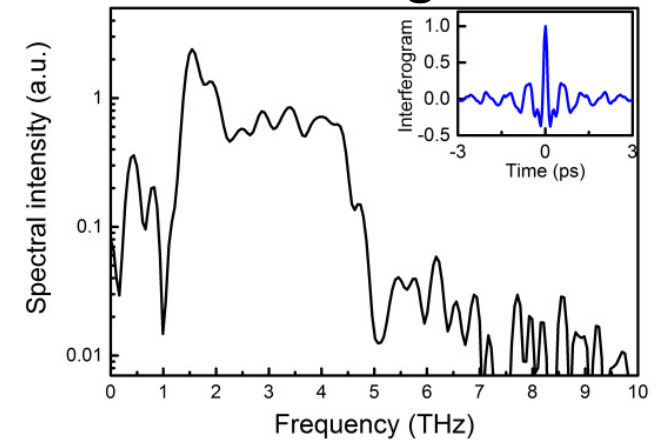
# Generation of mJ Single Pulses with Electric Field Exceeding 80 MV/cm\*

\*C. Vicario, A.V. Ovchinnikov, S.I. Ashitkov, M.B. Agranat, V.E. Fortov, and C. P. Hauri. Optics Letters, Vol. 39, Iss. 23, 2014.

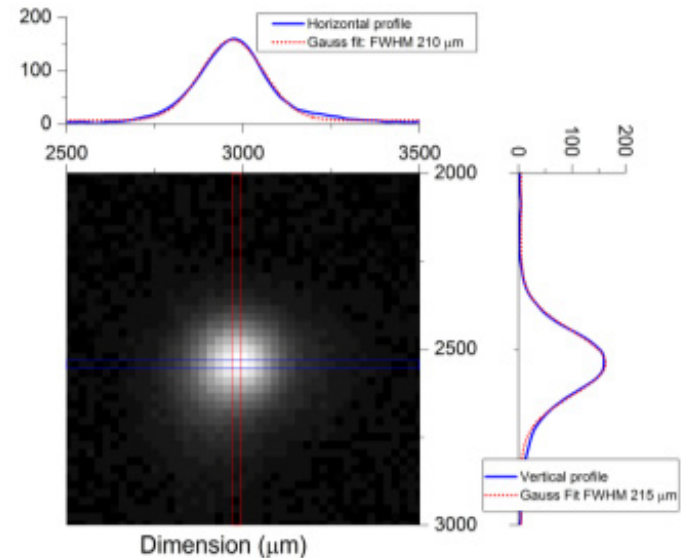


## The single-cycle, phase-stable THz pulse parameters:

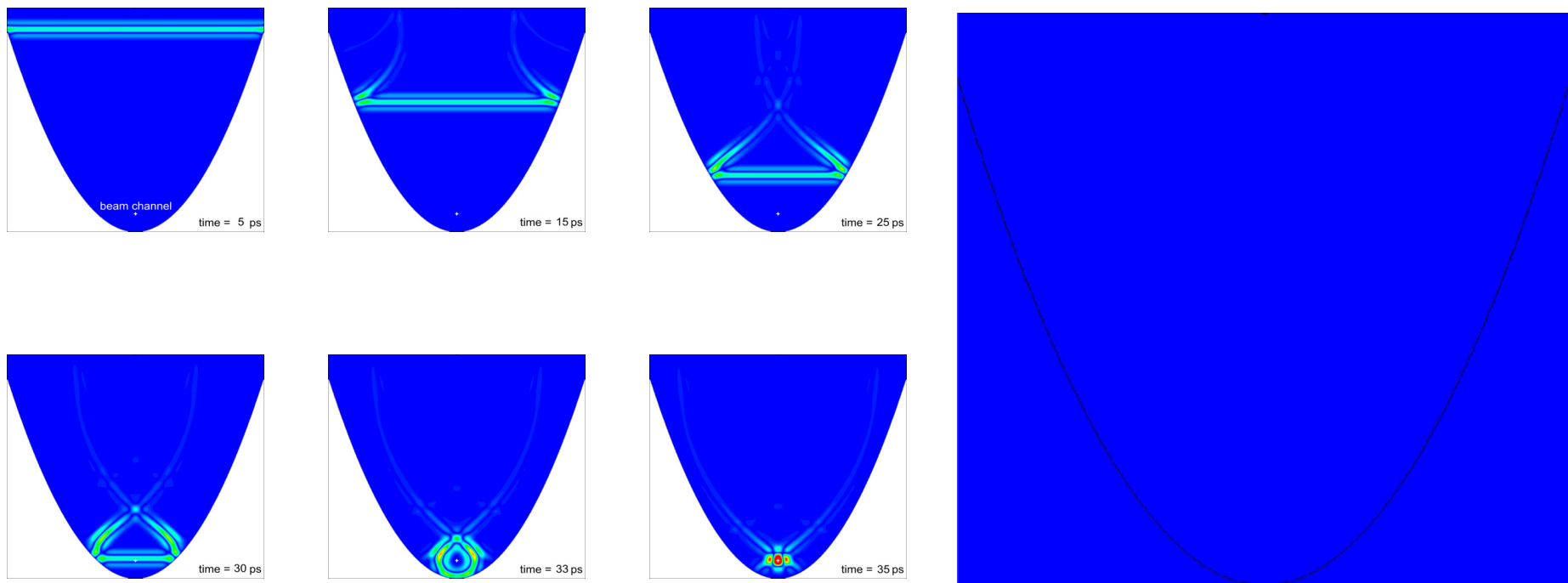
- THz pulse energy up to 1 mJ
- Conversion efficiency > 3%
- THz field strength **80 MV/cm**
- Frequency range 0.1 – 5 THz
- Power up to 10 GW



Emitted THz spectrum retrieved by the interferometric autocorrelation (blue curve in the inset) using a THz Michelson interferometer. THz beam profile for DSTMS

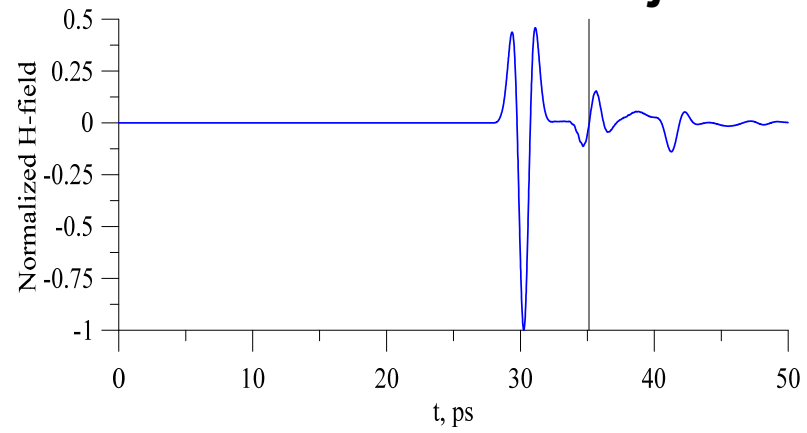
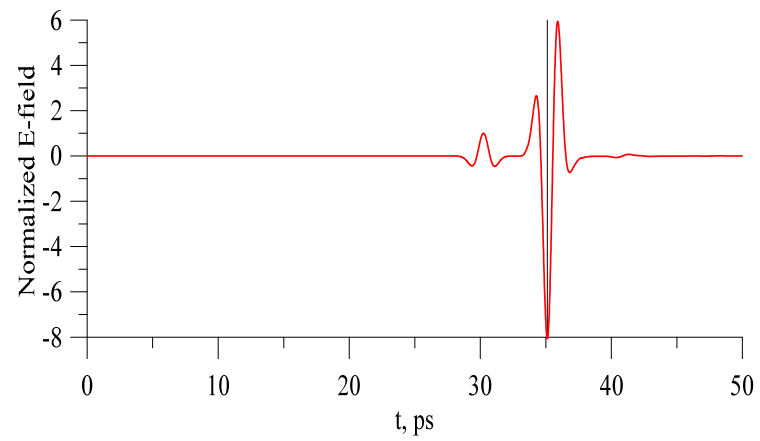


High-field THz have been produced by optical rectification in a large-size organic crystal by a powerful pump lasing. The phase-locked single-cycle pulses carry peak fields of more than **80 MV/cm** at diffraction limited spot size. The scheme has **3%** conversion efficiency.



Field distributions at the parabolic mirror while focusing the short THz pulse, for six sequential instants in time.

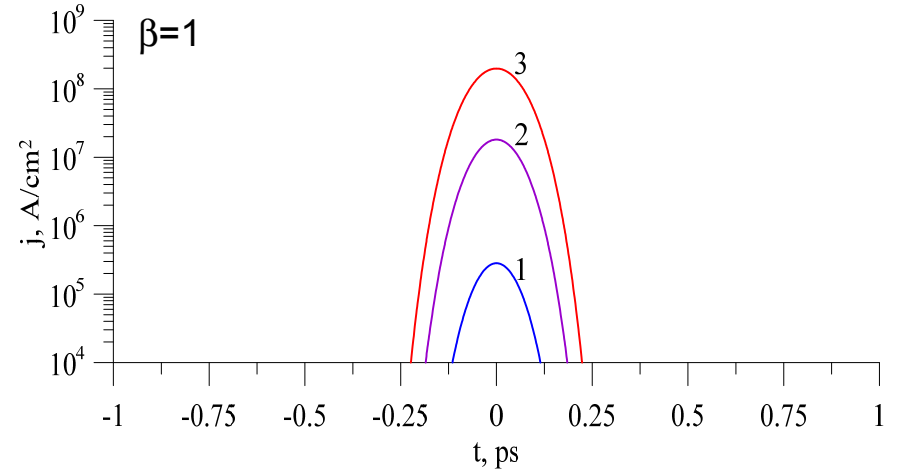
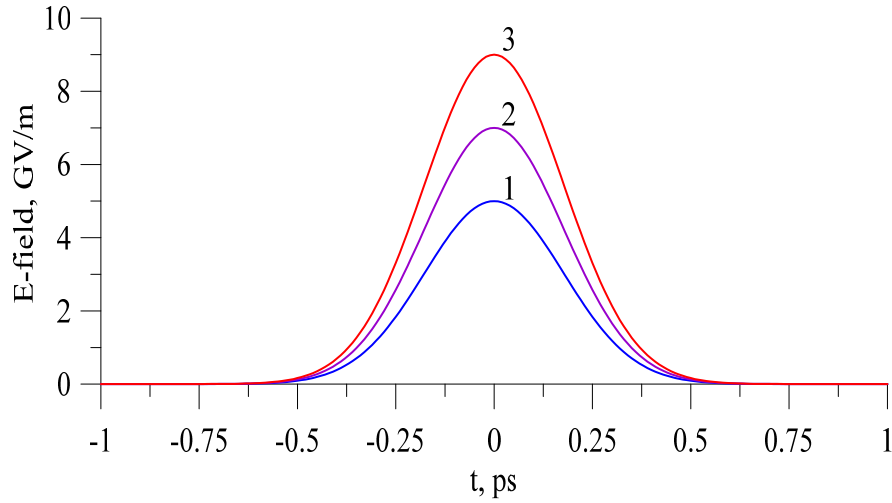
***Deflecting magnetic field is zero at injection time!***



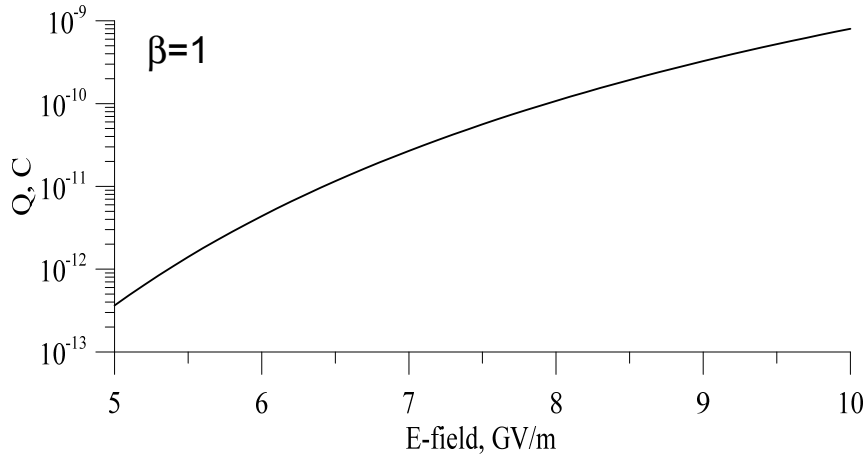
Electric (a) and magnetic (b) field components at the focus of the parabolic mirror.

Fowler-Nordheim current:

$$J_{FN} = \frac{1.54 \cdot 10^{-6}}{\phi} F^2 \exp\left(\frac{-6.83 \cdot 10^7 \phi^{3/2} f(3.79 \cdot 10^{-4} \sqrt{F} / \phi)}{F}\right)$$

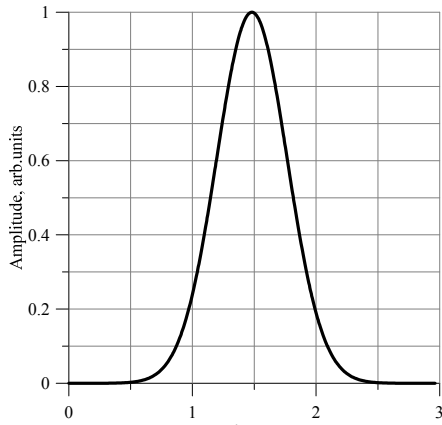


Anticipated parameters of the targeted THz-gated injector

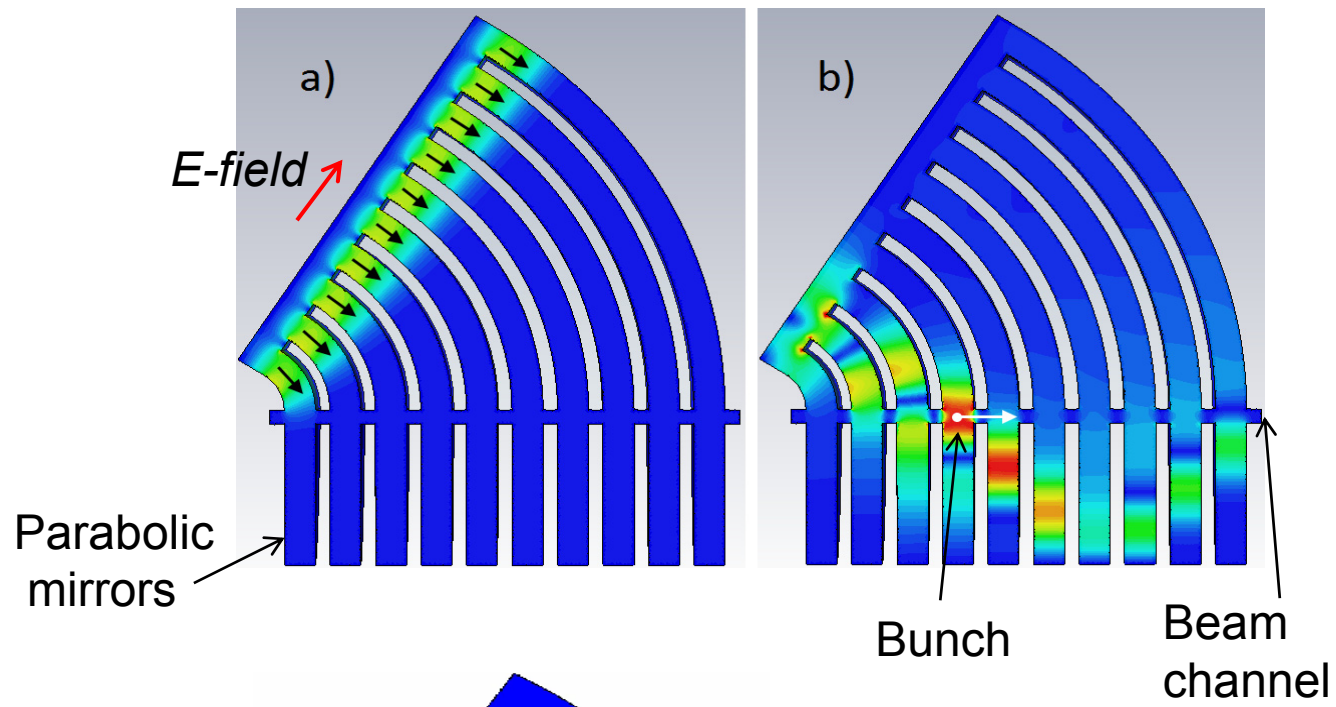


Maximum electric field on cathode (GV/m)	8
Effective bunch length (ps)	0.13
Effective cathode radius (mm)	$8 \times 10^{-3}$
Bunch charge (pC)	25
$\mathcal{E}_{th}$ (mm×mrad)	$9 \times 10^{-4}$
$\mathcal{E}_{sc}$ (mm×mrad)	0.13
$\mathcal{E}_{RF}$ (mm×mrad)	$7 \times 10^{-3}$
Brightness (A/m <sup>2</sup> ×rad <sup>2</sup> )	$2.2 \times 10^{16}$

Several THz high-gradient accelerating gaps are able to enhance energy of bunches considerably.

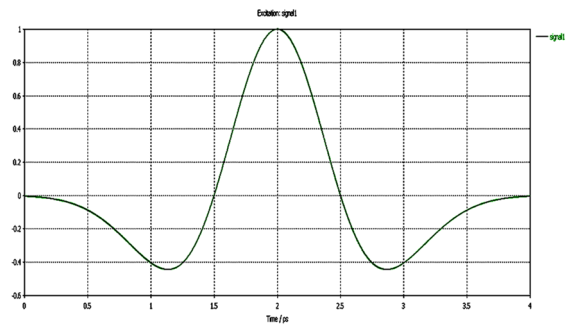


Shape of the incident THz pulse

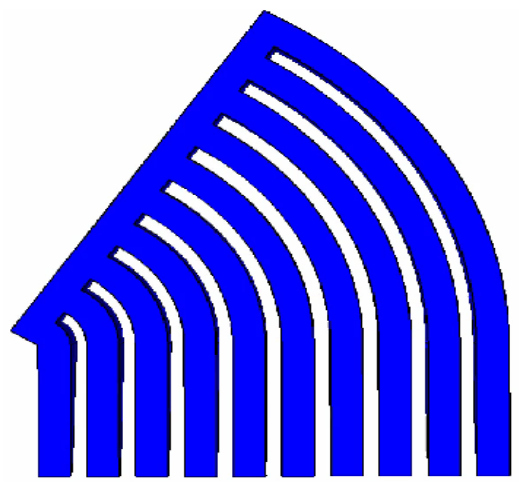


Parabolic mirrors

Bunch  
Beam channel

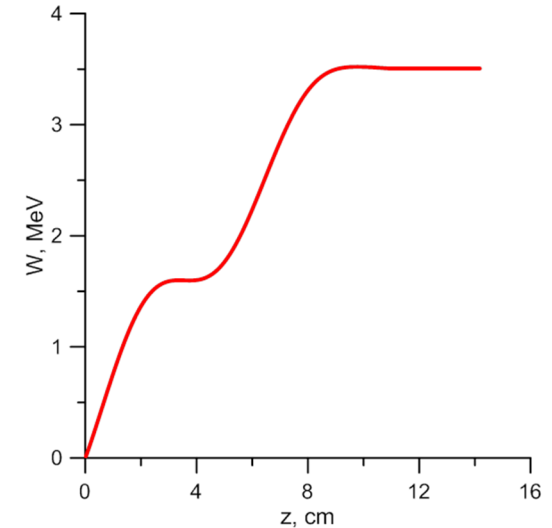
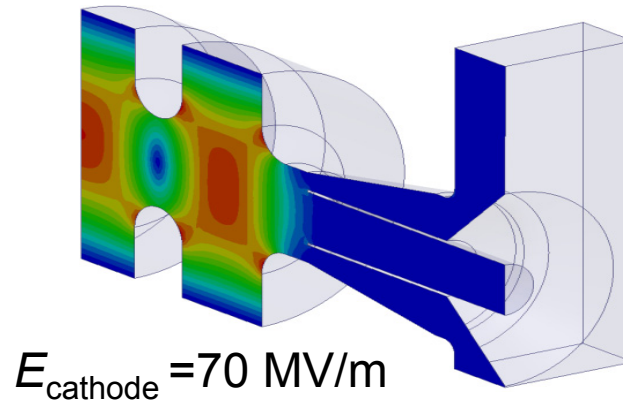
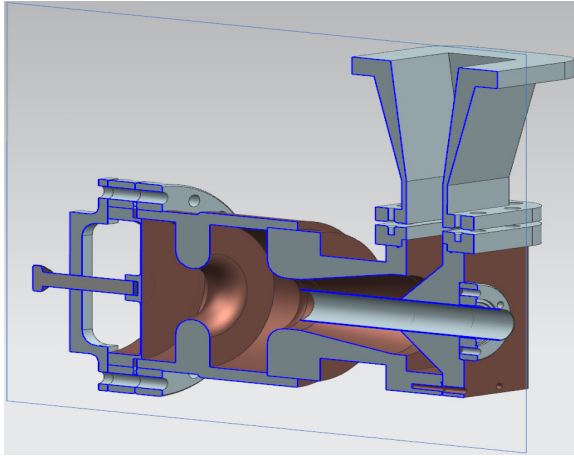


Shape of the incident THz pulse



Period – 150  $\mu\text{m}$ , gap between cells - 50  $\mu\text{m}$ , beam channel size – 50  $\mu\text{m}$ , aperture of parabolic mirror – 2 mm, focus – 0.5 mm, field in focal point – 1 GV/m, bunch length – 6 ps, gained energy – 0.4 MeV (gradient is about 300 MV/m)

# A 2.45 GHz Photoinjector gun at IAP RAS



Conventional 1,5 cell design:

Parameters	Value
Frequency	2.45 GHz
Cavity length	11.74 cm
Laser pulse duration	10 ps
Magnetic field	1.07 T
Bunch charge	100 pC
Laser spot radius	1 mm
Cathode field	70 MV/m
Injection phase	-40°
Average energy	3.5 MeV
Transverse emittance	1,4 mm×mrad
Energy spread	0.2%

1,5 cell + THz injector design:

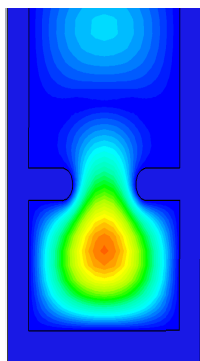
Parameters	Value
Frequency	2.45 GHz
Cavity length	11.74 cm
Bunch duration	0.09 ps
Magnetic field	1.34 T
Bunch charge	>25 pC
Beam radius at cathode	0.1 mm
Cathode THz field	5 GV/m
Injection phase	-27°
Average energy	4 MeV
Transverse emittance	0.9 mm×mrad
Energy spread	1 %

The use of THz injector helps to increase brightness by factor more than 50!

# Planned 38 GHz experiment

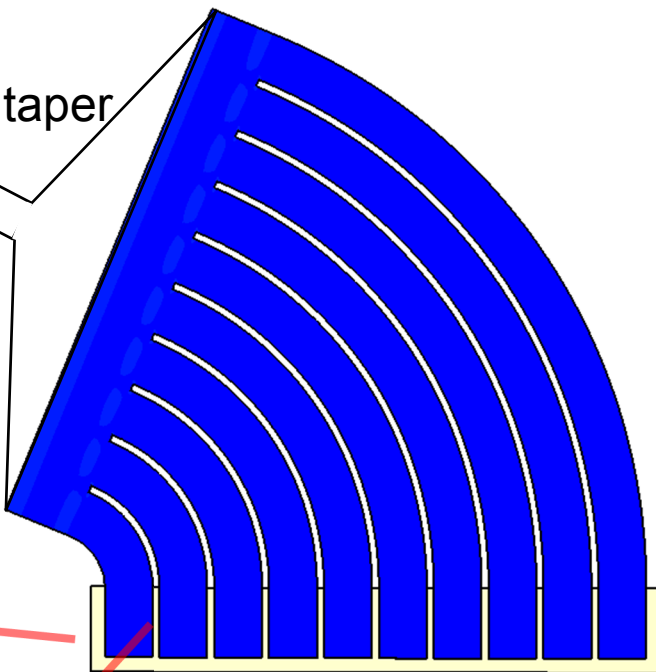


38 GHz, 1-2 GW, 300 ps

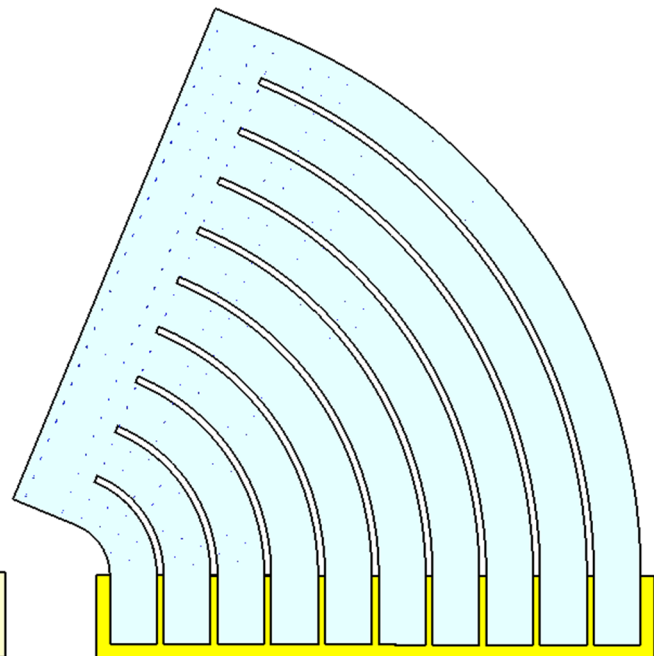


Resonator  
 $Q = \pi \cdot f \tau \approx 35$

taper



Set of resonators



length=44 mm  
width=8.4 mm

Beam channel

50 MeV,  
1 pC

60.4 MeV

Simulation of acceleration for long bunch (gradient is about 230 MV/m)

## Conclusion

Three concepts were proposed:

- 1) to apply short-pulse, high-power RF sources maintaining high cathode fields;
- 2) to apply cold diamond photocathode producing low-emittance bunches;
- 3) to use ultrafast terahertz gating providing preliminary acceleration of bunches.

These concepts are able to provide  $\sim 10^{16}$  A/m<sup>2</sup>×rad<sup>2</sup> beam brightness.